

Docket No.: F51176

FORM PTO-1595 (Modified)  
(Rev. 03-01)  
OMB No. 0651-0027 (exp. 5/31/2002)  
P08/REV03

RECORDATION FORM COVER SHEET

U.S. DEPARTMENT OF COMMERCE

Patent and Trademark Office

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To the Director of the United States Patent and Trademark Office: Please record the attached original documents or copy thereof.

1. Name of conveying party(ies):  
**Shipley Company, L.L.C.**

2. Name and address of receiving party(ies):

Name: **Eternal Technology Corporation**

Internal Address: \_\_\_\_\_

Additional names(s) of conveying party(ies) attached?  Yes  No

3. Nature of conveyance:

- Assignment  Merger
- Security Agreement  Change of Name
- Other \_\_\_\_\_

Street Address: **1800 Touchstone Road**

City: **Colonial Heights** State: **VA** ZIP: **23834**

Execution Date: **March 18, 2003**

Additional name(s) & address(es) attached?  Yes  No

4. Application number(s) or patent numbers(s):

If this document is being filed together with a new application, the execution date of the application is: \_\_\_\_\_

A. Patent Application No. (s)

B. Patent No. (s)

**09/995,880**

**6,057,079**  
**6,455,231**

Additional numbers attached?  Yes  No

5. Name and address of party to whom correspondence concerning document should be mailed:

6. Total number of applications and patents involved: **3**

Name: **Frank S. DiGiglio, Esq., Reg. No. 31,346**

7. Total fee (37 CFR 3.41):.....\$ **120.00**

Internal Address: **Scully, Scott, Murphy & Presser**

- Enclosed - Any excess or insufficiency should be credited or debited to deposit account
- Authorized to be charged to deposit account

Street Address: **400 Garden City Plaza**

8. Deposit account number:

**19-1013**

City: **Garden City** State: **NY** ZIP: **11530**

(Attach duplicate copy of this page if paying by deposit account)

DO NOT USE THIS SPACE

9. Statement and signature.

To the best of my knowledge and belief, the foregoing information is true and correct and any attached copy is a true copy of the original document.

**Frank S. DiGiglio, Esq., Reg. No. 31,346**



**April 19, 2005**

Name of Person Signing

Signature

**19**

Date

Total number of pages including cover sheet, attachments, and document:

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PATENT

CH \$120.00 191013 09995880

## GLOBAL INTELLECTUAL PROPERTY ASSIGNMENT and LICENSE AGREEMENT

THIS GLOBAL INTELLECTUAL PROPERTY ASSIGNMENT and LICENSE AGREEMENT (this "Assignment") is effective as of March 18, 2003 (the "Effective Date") by and among Shipley Company, L.L.C., a Delaware limited liability company ("Seller"), Morton International, Inc., an Indiana corporation ("Morton"), and Eternal Technology Corporation, a Virginia corporation located at 1800 Touchstone Road, Colonial Heights, Virginia 23834 USA ("Buyer").

### Background

Seller and Buyer entered into a Purchase Agreement, dated as of the date hereof (the "Purchase Agreement"), pursuant to which Seller or its Selling Affiliate, Morton, is (i) selling, assigning, transferring and conveying certain assets to Buyer (including, without limitation, all of Seller's or Morton's right, title and interest in certain of the Intellectual Property (as defined therein) and Buyer is purchasing such assets and (ii) licensing certain assets to Buyer (including certain of the Intellectual Property (as defined therein) and Buyer is licensing such assets.

### Terms

NOW THEREFORE, in consideration of the above premises and for other good and valuable consideration, the receipt and sufficiency of which are hereby acknowledged, and with the intent to be legally bound, the parties hereto hereby agree as follows:

1. Capitalized terms used herein without definition shall have the respective meanings ascribed such terms in the Purchase Agreement except for the term "Territory" which shall have the meaning ascribed in the Joint Venture Agreement between Morton and Nippon-Gohsei.
2. Effective as of the Effective Date, and subject to the terms and conditions of the Purchase Agreement, Seller or Morton hereby sells, assigns, transfers and conveys exclusively throughout the world (except as otherwise stated herein) the following assets (but excluding any such assets that constitute Excluded Assets) to Buyer to be held and enjoyed by Buyer for its own use and benefit and for its successors and assigns as the same would have been held by Seller or Morton had this Assignment not been made:
  - A. subject to an exclusive license to Nichigo-Morton in the Territory to know-how relating to the products listed in Schedule 3.6.III of the Purchase Agreement attached hereto and any enhanced or refined versions thereof, all right, title and interest in and to all trade secrets, formulae, know-how or technology owned, controlled or held by Seller or Morton that are exclusively or required to be used in the production, manufacture and marketing of the Product Line and any and all improvements thereto and all claims, demands and rights to reconvey that Seller or Morton has or may have for past and future misappropriation or other misuse, if any, and all rights to compromise, sue for, and collect on such claims, demands and right to recovery related to such use in the production, manufacture and marketing of the Product Line;
  - B. all right, title and interest in and to all patents, patent applications, inventions, and invention disclosures, owned, controlled or held by Seller or Morton that are shown in **PATENT** Schedule 1.1(p)(i) of the Purchase Agreement attached hereto and any and all improvements thereto, and

all reissues, divisions, continuations, continuations-in-part, extensions thereof, and supplementary protection certificates related thereto, all claims, demands and rights to recovery that Seller or Morton has or may have for past and future infringements, misappropriation or other violations of such patents, patent applications, inventions and invention disclosures, if any, and all rights to compromise, sue for, and collect on such claims, demands and rights to recovery;

C. all right, title and interest, but subject to an exclusive license to Nichigo-Morton in the Territory, in and to all patents, patent applications, inventions, and invention disclosures, owned, controlled or held by Seller or Morton that are shown in Table 2 of Schedule 1.1(p)(i) of the Purchase Agreement also attached hereto and any and all improvements thereto, and all reissues, divisions, continuations, continuations-in-part, extensions thereof, and supplementary protection certificates related thereto, all claims, demands and rights to recovery that Seller or Morton has or may have for past and future infringements, misappropriation or other violations of such patents, patent applications, inventions and invention disclosures, if any, and all rights to compromise, sue for, and collect on such claims, demands and rights to recovery, subject to the license to Nichigo-Morton.

D. subject to an exclusive license to Nichigo-Morton in the Territory, all right, title and interest in and to all registered and unregistered trademarks, trademark rights, service marks, service names, service mark rights, trade names, trade name rights, trade dress, slogans, logotypes and designs, and other indicia of origin, and any licenses relating to the foregoing, owned, controlled or held by Seller or Morton that are shown in Schedule 1.1(p)(ii) of the Purchase Agreement, which is attached hereto, all income, royalties, damages and payments now or hereafter due or payable with respect thereto, all claims, demands and rights to recovery that Seller or Morton has or may have for past and future infringements, dilution or other violations relating thereto, if any, and all rights to compromise, sue for, and collect on such claims, demands and rights to recovery, and the goodwill of the business relating thereto; and

E. except as otherwise provided in Section 2.D above, all right, title and interest in and to all registered and unregistered trademarks, trademark rights, service marks, service names, service mark rights, trade names, trade name rights, trade dress, slogans, logotypes and designs, and other indicia of origin, and any licenses relating to the foregoing, owned, controlled or held by Seller or Morton that are exclusively used or held for use in the Business (the "Trademarks"), together with all registrations and applications for registration of the Trademarks, including, without limitation, the trademarks shown in Schedule 1.1(p)(iii) of the Purchase Agreement, which is attached hereto, all income, royalties, damages and payments now or hereafter due or payable with respect thereto, all claims, demands and rights to recovery that Seller or Morton has or may have for past and future infringements, dilution or other violations of such Trademarks, if any, and all rights to compromise, sue for, and collect on such claims, demands and rights to recovery, and the goodwill of the business symbolized by the Trademarks;

3. Effective as of the Effective Date, and subject to the terms and conditions of the Purchase Agreement, Seller or Morton hereby grants to Buyer:

A. an irrevocable, exclusive, worldwide, fully paid-up license under the patents listed in Table 3 of Schedule 1.1(p)(i) of the Purchase Agreement and attached hereto and any and all improvements thereto, to make, have made, use, offer for sale, sell and import products, services and uses for applications only within the Business, including the right to sublicense purchasers of Buyer to use the products, services and uses only within the Business; and

B. an irrevocable, exclusive, worldwide, fully paid-up license subject to an exclusive license to Nichigo-Morton in the Territory under the patents listed in Table 4 of Schedule 1.1(p)(i) of the Purchase Agreement and attached hereto and any and all improvements thereto, to make, have made, use, offer for sale, sell and import products, services and uses for applications only within the Business; and

offer for sale, sell and import products, services and uses for applications only within the Business, including the right to sublicense purchases of Buyer to use the products, services and uses only within the Business, subject to the license to Nichigo-Morton.

4. Effective as of the Effective Date, and subject to the terms and conditions of the Purchase Agreement, Buyer hereby grants to Seller an irrevocable, non-exclusive, worldwide, fully paid-up license under the patents, patent applications, inventions and invention disclosures in Tables 1 and 2 of Schedule 1.1(p)(i) of the Purchase Agreement attached hereto, and any and all improvements thereto made by Buyer, to make, have made, use, offer for sale, sell and import products, services and uses for applications only outside the Business, including the right to sublicense purchasers of Seller to use the products, services and uses only outside the Business. In the event the parties disagree as to whether any of the patents, patent applications, inventions and invention disclosures licensed to Seller under this Section 4 are being used outside the Business, the Representatives of the parties (as defined in Section 3.(iv) of the Transition Agreement) will meet to resolve the issue.

5. Seller and Buyer shall each take, and shall cause their respective Affiliates to take, any and all additional actions as may be necessary or appropriate to effect the transactions contemplated by this Assignment. Such actions may include, without limitation, the execution of additional documents to record the assignments and transfers made in this Assignment and the filing of such documents with the appropriate domestic and foreign governmental authorities. At Buyer's sole expense, after the Closing Date, Seller shall take, and shall cause its Affiliates to take, any and all actions that are necessary or appropriate to maintain any and all assets assigned under this assignment in force until such time that the Buyer can reasonably be expected to assume such obligations.

6. The terms and conditions of the Purchase Agreement shall govern, supersede and prevail.

7. Neither party hereto may assign, delegate or transfer its rights under this Assignment without the prior written consent of the other party hereto, except that Buyer may assign, delegate or transfer any such right without such consent. This Assignment is binding upon and shall inure to the benefit of the parties hereto and their respective successors and permitted assigns.

8. Subject to applicable law, this Assignment and License may be amended, modified and supplemented by written instrument authorized and executed by Buyer and Seller at any time with respect to any of the terms contained herein. No waiver by any party hereto of any provisions hereof shall be effective unless explicitly set forth in writing and executed by the party so waiving. The waiver by either party hereto of a breach of any provisions of this Assignment shall not operate or be construed as a waiver of any other or subsequent breach.

9. This Assignment and License may be executed by the parties hereto in separate counterparts, each of which when so executed and delivered shall be an original, but all such counterparts shall together constitute one and the same instrument.

10. This Assignment and License shall be governed by and construed and enforced in accordance with the laws of the State of Delaware, excluding conflicts of law principles that would cause the application of laws of any other jurisdiction.

IN WITNESS WHEREOF, the parties hereto have caused this Assignment to be executed as of this 18<sup>th</sup> day of March, 2003 to be effective as of the Effective Date.

SHIPLEY COMPANY, L.L.C.

By: *[Signature]*

Name: BRONDEAU  
Title: President and CEO

MORTON INTERNATIONAL, INC.

By: *[Signature]*

Name: BRONDEAU  
Title: Attorney in fact for the president of Morton.

ETERNAL TECHNOLOGY CORPORATION

By: *[Signature]*  
Name: Yung S. Kao  
Title: President

Case No. 2158 Date DEC 10 2004  
本影本或副本與原本或正本無異在臺灣臺北地方法院所屬民間公證人陳建源事務所認證。公證人陳建源  
Attested at the Cheng, Chien-Yuan Notary Public Office, Taiwan Taipei District Court, R.O.C., that this document is a true & complete copy of its original.

Notary Public  
Cheng, Chien-Yuan  
2F, No. 62, Sec. 2, Chang An E. Rd, Taipei, Taiwan  
Tel:(02)25074587

Agreed and Accepted:  
ETERNAL CHEMICAL CO., LTD.

By: *[Signature]*  
Name: Allen Kao  
Title: President

案號: 2151 日期: DEC 10 2004  
Case No.: 2151 Date: DEC 10 2004  
本文件之簽名或蓋章在臺灣臺北地方法院所屬民間公證人陳建源事務所認證。公證人陳建源  
Attested at the Cheng, Chien-Yuan Notary Public Office, Taiwan Taipei District Court, R.O.C., that the signature(s)/seal(s) of ETERNAL TECHNOLOGY CORPORATION in this document is/are authentic.

Notary Public  
Cheng, Chien-Yuan  
2F, No. 62, Sec. 2, Chang An E. Rd, Taipei, Taiwan  
Tel:(02)25074587

This Assignment was signed in my presence this 18<sup>th</sup> day of March, 2003. Cheng, Chien-Yuan

*[Signature]*  
Notary Public  
My commission expires: Aug. 9. 2007

本認證僅證明簽名或蓋章屬實,至文件內容之真偽則不在證明之列。如有附件,亦不在認證範圍內。

**Schedule 3.6III****Dryfilm Products**

AX1.0	AX1.5	AX2.0	UF0.5	UF1.5	LC300
HG1.0	HG1.5(TK1.5)		GH2.0	GA1.0	GA1.3
GA2.0	GA3.0	GA4.0	LP2.0	LP3.0	VG0.5
AP2.0	AT1.2	TE1.0	TE1.3	TE1.5	TE2.0
5020	5038	5050			

**Soldermask Products**

Conformask2015	Conformask2023	Conformask2515	Conformask2523
DM3.0	DM4.0	Dynamask 5010	Dynamask 5030
Dynamask 5040	KM3.0	KM4.0	

### Schedule 1.1(p)(i)

In each of Tables 1-4 of this Schedule 1.1(p)(i), Assignee M refers to Morton International, Inc. and Assignee S refers to Seller.

The patents and patent applications listed in Tables 1 and 2 of this Schedule 1.1(p)(i) are transferred to Buyer subject to a non-exclusive license from Buyer to Seller for use outside the Business. Accordingly, Buyer hereby grants the Seller, and Seller hereby accepts, an irrevocable, non-exclusive, worldwide, fully paid-up license under the patents and patent applications in Tables 1 and 2 of this Schedule, and any and all improvements thereto made by Buyer, to make, have made, use, offer for sale, sell and import products, services and uses for applications only outside the Business, including the right to sublicense purchasers of Seller to use the products, services and uses only outside the Business.

The patents and patent applications in Table 1 are to be transferred to Buyer.

**Table 1**

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	1096-35-00	Flexible Fast Processing of Photopolymerizable Compositions	Canada	Pat. No. 1216219	1/16/1984
M	1114-35-00 (51418)	Flexible Fast Processing of Photopolymerizable compositions	Canada Spain Israel U.S.A.	Pat. No. 1213092 Pat. No. 533132 Pat. No. 72040 Pat. No. 4539286	5/23/1984 6/5/1984 6/5/1984 6/6/1983
M	1114-35-02 (51418)	Process of Using a Flexible, Fast Processing Photopolymerizable Compositions	U.S.A.	Pat. No. 4610951	7/25/1985
M	1763-35-00 (51421)	Dry Film For Forming a Conformable Mask and Method of Application to a Printed Circuit Board or the Like	U.S.A.	Pat. No. 4889790	2/26/1988
M	1763-35-03 (51421)	Dry Film for Forming a Conformable Mass and Method of Application to a Printed Wiring Board	U.S.A.	Pat. No. 5213945	7/25/1991
M	1763-35-34 (51421)	Method of Application of a Conforming Mask to a Printed Circuit Board	U.S.A.	Pat. No. 5164284	11/19/1991
M	1961-35-17	Photoimageable Compositions having Improved Adhesion Promoter	U.S.A.	Pat. No. 5320933	11/20/1992
M	2284-35-00	Photoresist processing for improved resolution having a bake step to remove the tackiness of the laminated photosensitive layer prior to contact imagewise exposure	EPC: Austria, Belgium, France, Germany, Italy, Netherlands, Spain, Sweden, Switzerland, U.K. U.S.A.	Pat. No. 0713146      Pat. No. 5391458	11/16/1994      12/18/1992
M	2446-35-00	1,3-diaza-9-thiaanthracene-2,4-diones and photopolymerizable mixtures containing same	Canada	Pat. No. 1213274	9/1/1983

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	2479-35-00 (51435)	Radiation polymerizable mixture, copolymer contained therein and a process for the preparation of the copolymer	EPC: Austria, Belgium, France, Germany, Italy, Netherlands, Sweden, Switzerland, U.K. Japan South Africa Singapore U.S.A.	Pat. No. 0173057  Pat. No. 1971978 Pat. No. 855194 Pat. No. 91907980 Pat. No. 4705740	7/17/1985  7/25/1985 7/10/1985 7/17/1985 7/11/1985
M	2479-35-02 (51435)	Radiation polymerizable mixture, copolymer contained therein and a process for the preparation of the copolymer	EPC: Austria, Belgium, France, Germany, Italy, Netherlands, Sweden, Switzerland, U.K.	Pat. No. 0271077	7/17/1985
M	2618-35-14 (51442)	Photopolymerizable composition containing an N-Heterocyclic photo initiator	U.S.A.	Pat. No. 6114091	11/3/1997
M	2618-35-97 (51443)	Photopolymerizable composition and photopolymerizable recording material prepared using this composition	U.S.A.	Pat. No. 6127091	11/3/1997
M	2921-35-02 (51444)	Esterified Styrene/Maleic anhydride polymer	U.S.A.	Pat. No. 5773518	8/15/1997
M	2921-35-29 (51444)	Method of Producing a resist pattern by contact imaging a photoimageable composition providing a tack-free surface.	U.S.A.	Pat. No. 5698376	3/20/1996
M	<del>3500-35-00</del> ( <del>51449</del> )	Photoimageable compositions having improved flexibility adhesion and stripping characteristics	Australia Canada China Hong Kong Japan Korea Singapore Taiwan U.S.A.	Pat. No. 705608 App No. 2249527 App No. 981230539 App No. 991033001 App No. 10337099 App No. 9850659 Pat. No. 77202 App No. 87116833 Pat. No. 5952153	10/12/1998 10/5/1998 12/1/1998 7/30/1999 11/27/1998 11/25/1998 10/8/1998 10/7/1998 12/1/1997
M	<del>3501-35-00</del>	Photoimageable compositions containing photopolymerizable urethane oligomers and dibenzoate	Australia China Hong Kong Japan Korea Singapore Taiwan U.S.A.	App No. 8840098 App No. 981230547 App No. 991033039 App No. 10337100 Pat. No. 0269566 Pat. No. 72876 App No. 87116832 Pat No. 5,939,239	10/12/1998 12/1/1998 7/30/1999 11/27/1998 11/25/1998 10/9/1998 10/9/1998 12/1/1997
M	3506-35-00 (51451)	Photoimageable composition having improved stripping properties in aqueous alkaline solutions	China Hong Kong Japan Korea Taiwan U.S.A.	App No. 991041550 App No. 991051231 App No. 1172207 Pat. No. 0310653 App No. 88102006 Pat. No. 5922509	3/18/1999 11/9/1999 3/17/1999 3/17/1999 2/9/1999 3/5/1998



Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	3608-35-00	Photoimageable composition	EPC Australia Canada China Japan Korea Singapore Taiwan U.S.A.	App No. 983095639 Pat. No. 707217 Pat. No. 2252240 App No. 981230458 App No. 10337103 Pat. No. 0303098 Pat. No. 72883 App No. 87119507 Pat. No. 6004725	11/23/1998 10/27/1998 10/27/1999 12/1/1998 11/27/1999 11/25/1998 11/2/1998 11/24/1998 7/17/1998
M	3630-35-00 (50862)	Photoimageable compositions having flexibility and stripping ability	U.S.A.	Pat. No. 6322951	12/11/1999
M	3630-35-17 (50875)	Photoimageable compositions having improved stripping ability and resolution	EPC China Hong Kong Japan Korea Taiwan U.S.A.	App No. 99309618.9 App No. 991248007 App No. 00107960.1 App No. 99353667 App No 1019990054878 App No. 88121429 Pat. No. 6319653	11/30/1999 12/10/1999 11/30/1999 12/13/1999 12/31/1999 12/7/1999 8/18/1999
M	3630-35-24 (50863)	Photoimageable compositions having improved flexibility and stripping ability	EPC China Hong Kong Japan Korea Taiwan U.S.A.	App No. 99309619.7 App No. 99126102 App No. 00107976.3 App No. 99353717 App No. 1019990055 App No. 88121428 Pat. No. 6329123	11/30/1999 12/10/1999 11/3/1999 12/13/1999 12/7/1999 2/29/2000 7/30/1999
S	50152	Dry film photoresist construction suitable for rolling up on itself	U.S.A. Europe Japan	Pat. No. 6,057,079 Pub. No. 905564 Pub. No. 11237723	
S	50485	Dry film photoimageable compositions	U.S.A. Japan EPC: Germany, France, U.K., Italy, Netherlands	Pat. No. 6,455,231, Pat. No. 2001194778 Pat. No. 1098223	
S	50661	Photoresists having increased photospeed	EPC Japan Korea Taiwan	Pending Pending Pending Pending	
S	50884	Photoresist compositions	EPC U.S.A. China Japan Korea Taiwan	Pending 09/995880 Pending Pending Pending Pending	11/28/2001 11/28/2001 11/28/2001 11/27/2001 11/28/2001
S	50967	Photoresist Compositons	EPC U.S.A. China Japan Korea Taiwan	Pending 09/995921 Pending Pending Pending Pending	11/28/2001 11/28/2001 11/28/2001 11/27/2001 11/28/2001
S	50896	Photopolymerizable Compositions that Exhibit Improved Stripping Ability and Chemical Resistance Onened 10/1/00		Not yet filed <b>PATENT</b>	

REEL: 016097 FRAME: 0424

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
S	51325	Photopolymerizable Compositions that Exhibit Improved Stripping Ability and Chemical Resistance Opened 12/15/01		Not yet filed	

The patents and patent applications in Table 2 are to be transferred to Buyer, subject to an exclusive license to Nichigo-Morton in the Territory as defined in the Joint Venture Agreement between Morton International, Inc. and Nippon-Gohsei.

Table 2

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	1763-35-24 (51421)	Dry Film Photoresist for Forming a Conformable Mask and Method of Application to a Printed Circuit Board or the Like	EPC: Austria, Belgium, France, Germany, Italy, Liechtenstein, Netherlands, Spain, Sweden, Switzerland, U.K. Australia Canada Japan Korea Singapore U.S.A.	Pat. No. 0330339  Pat. No. 625637 Pat. No. 1304169 Pat. No. 251945949 Pat. No. 59745 Pat. No. 50432 Pat. No. 4992354	2/9/1989  2/15/1989 2/24/1989 2/17/1989 2/25/1989 2/10/1996 10/28/1988
M	2122-35-00	Photosensitive Laminate Having Dual Intermediate Layers: Dry film laminate for PCB	EPC: Belgium, France, Germany, Italy, Netherlands, Spain, U.K. Canada Hong Kong Japan Singapore U.S.A.	Pat. No. 0565233  Pat. No. 2089822 Pat. No. 1005154 Pat. No. 2572928 Pat. No. 50525 Pat. No. 5270146	3/5/1993  2/18/1993 5/19/1998 3/25/1993 3/5/1993 4/7/1992
M	2448-35-00 (51431)	Radiation polymerizable mixtures with crosslinkable binder	EPC: Austria, Belgium, Germany, Spain, France, UK, Italy, Netherlands, Sweden, Switzerland  Canada Hong Kong Israel Japan Korea Singapore USA	Pat. No. 0141921  Pat. No. 1226392 Pat. No. 231988 Pat. No. 72683 Pat. No. 2082732 Pat. No. 50502 Pat. No. 87907853 Pat. No. 4572887	8/7/1984  8/14/1984 8/7/1984 8/14/1984 8/16/1984 8/14/1984 8/7/1984 8/13/1984

PATENT

REEL: 016097 FRAME: 0425

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	2461-35-00	Radiation-polymerizable mixture	U.S.A. South Africa Japan Korea Canada Finland Israel	Pat. No. 4956264 Pat. No. 8608307 Pat. No. 62119541 Pat. No. 9407774 Pat. No. 1300786 Pat. No. 8604625 Pat. No. 80582	1/22/1986
M	2463-35-00	Photopolymerizable compositions, a leuco dye and a leuco dye stabilizer	EPC: Austria, Belgium, France, Italy, Germany, Netherlands, Spain, Sweden, Switzerland, U.K. Canada Japan Korea Taiwan U.S.A.	Pat. No. 0311926  Pat. No. 1329043 Pat. No. 2645110 Pat. No. 129540 Pat. No. 39878 Pat. No. 4940647	10/7/1988  10/11/1988 10/14/1988 10/14/1988 9/24/1988 10/6/1988
M	2467-35-00	Radiation polymerizable composition and Recording material prepared from the composition	EPC: Austria, Belgium, France, Germany Italy, Netherlands, Spain, Sweden, Switzerland, U.K. Canada Japan Korea South Africa Taiwan	Pat. No. 033059  Pat. No. 589089218 Pat. No. 2788921 Pat. No. 140880 Pat. No. 891198 Pat. No. 46070	2/15/1989  2/15/1989 2/20/1989 2/23/1989 2/16/1989 2/3/1989
M	2469-35-00	Process for Stabilizing a Leuco-dye solution by means of a piperidine derivative	EPC: Austria, Belgium, France, Germany, Italy, Netherlands, Spain, Sweden, U.K. Australia Canada Finland Japan Korea Taiwan U.S.A.	Pat. No. 0363775  Pat. No. 628865 Pat. No. 2000051 Pat. No. 95477 Pat. No. 2063944 Pat. No. 123630 Pat. No. 45251 Pat. No. 5085669	10/2/1989  10/6/1989 10/2/1989 10/5/1989 10/7/1989 10/6/1989 10/6/1989 10/6/1989
M	2616-35-00	Photopolymerizable mixture and photopolymerizable copying material	Canada Japan U.S.A.	Pat. No. 2006074 Pat. No. 2821463 Pat. No. 5217845	12/20/1989 12/22/1989 9/26/1991
M	2618-35-00 (51441)	Photopolymerizable composition and photopolymerizable recording material prepared using this composition	EPC: France, Germany Switzerland, U.K. Japan Korea	Pat. No. 0474009  Pat. No. 2980743 Pat. No. 190200	8/19/1991  8/29/1991 8/28/1991

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	2921-35-24 (51444)	Photoimageable compositions having improved alkaline process resistance and tack-free surface	EPC: Austria, Belgium, France, Germany, Italy, Liechtenstein, Netherlands, Spain, Sweden, Switzerland, U.K. Australia Canada China Hong Kong Israel Japan Korea Mexico U.S.A.	Pat. No. 0726499	2/8/1996  2/2/1996 12/27/1995 2/9/1996 5/19/1998 12/15/1995 2/7/1996 2/6/1996 2/8/1996 8/3/1995

All rights, title and interest to the patents and patent applications listed in Tables 3 and 4 shall remain with Seller or its Selling Affiliate. Seller or its Selling Affiliate hereby grants the Buyer, and Buyer hereby accepts, an irrevocable, exclusive, worldwide, fully paid-up license under the patents and patent applications listed in Table 3 of this Schedule, to make, have made, use, offer for sale, sell and import products, services, and uses for applications only within the Business, including the right to sublicense purchases of Buyer to use the products, services and uses only within the Business.

**Table 3**

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	1558-35-17 (51426)	Photoinitiator Composition Containing Bis Ketocoumarin Dialkylamino Benzoate, Camphorquinone and/or a Triphenylimidazole Dimer: Photoinitiators are useful in photopolymerizable compositions which are polymerized by exposure to visible laser light.	U.S.A.	Pat. No. 4894314	11/16/1988
M	2449-35-00 (51432)	Process and Laminate for the Manufacture of through-hole plated electric printed circuit boards	U.S.A.	Pat. No. 4770900	3/16/1987

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	2521-35-00 (51437)	Waterborne photoresists having binders neutralized with amino acrylates: includes claims to a dry film.	EPC: Austria, Belgium, France, Germany, Italy, Liechtenstein, Netherlands, Spain, Switzerland, U.K. Canada China Hong Kong Israel Korea Mexico Singapore Taiwan U.S.A.	Pat. No. 0664488  Pat. No. 2133148 Pat. No. 1071911 App No. 981042118 App No. 112008 Pat. No. 144639 Pat. No. 198976 Pat. No. 49621 Pat. No. 075296 Pat. No. 5393643	10/27/1994  9/28/1994 11/21/1994 5/15/1998 12/16/1994 12/21/1994 10/18/1994 10/27/1994 9/24/1994 5/4/1994
M	2550-35-00 (51439)	Waterborne photoresists having binders with sulfonic acid functionality: has claims directed to a dry film.	U.S.A.	Pat. No. 5411837	5/5/1994
M	3277-35-17 (51447)	High resolution positive acting dry film photoresist	U.S.A.	Pat. No. 5981135	8/13/1997
M	3277-35-24 (51447)	High resolution positive acting dry film photoresist	EPC: Belgium, France, Germany, Italy, Netherlands, Spain, U.K. Canada China Japan Korea Malaysia Taiwan	Pat. No. 0848290  Pat. No. 2224312 App No. 971141835 App No. 9340012 Pat. No. 0278257 App No. 9705938 App No. 86117705	12/10/1997  12/10/1997 12/10/1997 12/9/1997 12/10/1997 11/25/1997
M	3502-35-00 (51450)	Photoimageable composition having improved flexibility	China EPC Hong Kong Japan Korea Singapore Taiwan U.S.A.	App No. 991071425 App No. 993039338 App No. 001006075 App No. 111292218 Pat. No. 0294549 App No. 99019390 App No. 88104047 Pat. No. 5952154	5/31/1999 5/20/1999 2/1/2000 5/10/1999 5/27/1999 4/23/1999 3/16/1999 5/29/1998
M	3629-35-00 (50698)	Photoimageable compositions having improved chemical resistance and stripping ability	U.S.A.	Pat. No. 6045973	12/11/1998
M	3629-35-24 (50698)	Photoimageable compositions having improved chemical resistance and stripping ability	EPC Australia Canada China Hong Kong Israel Japan Korea Singapore Taiwan U.S.A.	App No. 99309620.5 App No. 9963004 App No. 2291547 App No. 991261011 App No. 00107975.4 App No. 133218 App No. 99353696 App No. 10199900562 Pat. No. 79295 Pat. No. 155500 Pat. No. 6054252	11/30/1999 12/1/1999 12/3/1999 12/10/1999 11/30/1999 11/30/1999 12/13/1999 12/9/1999 12/19/1999 12/7/1999 7/30/1999

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
S	50775	Functionalized polymer: pendent urethane groups from the polymer backbone characterize the polymer and provide improved properties.	Provisionally filed in the U.S.	60/357,416	02/15/02
S	50956	Photoresist Compositions	EPC U.S.A. China Japan Korea Taiwan	Pending 10/118225 Pending Pending Pending Pending	4/10/2002 4/6/2002 4/18/2002 4/18/2002 4/16/2002 4/12/2002
S	51384	Modified initiator with chemical reactivity for photoimageable resists	Provisionally filed in U.S.	60/414759	9/30/2002
S	51486	Improved Photoresist	Provisionally filed in U.S.	60/414758	9/30/2002
S	51819	Functionalized Polymer	Provisionally filed in U.S.	App No. 60/432875	12/12/2002

Seller or its Selling Affiliate hereby grants the Buyer, subject to an exclusive license to Nichigo-Morton in the Territory as defined in the Joint Venture Agreement between Morton International, Inc. and Nippon-Gohsei, and Buyer hereby accepts, an irrevocable, exclusive, worldwide, fully paid-up license under the patents and patent applications listed in Table 4 of this Schedule, to make, have made, use, offer for sale, sell and import products, services and uses for applications only within the Business, including the right to sublicense purchasers of Buyer to use the products, services and uses only within the Business.

**Table 4**

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	2487-35-24 (51436)	Waterborne photoresists having associate thickness: May be used as a liquid or dry film.	EPC: Austria, Belgium, France, Germany, Italy, Liechtenstein, Spain, Netherlands, Switzerland, U.K. Australia Brazil Canada China Hong Kong Israel Japan Korea Mexico Taiwan U.S.A.	Pat. No. 066490  Pat. No. 660392 Pat. No. 94047383 Pat. No. 2131044 Pat. No. 200233 App No. 981042127 Pat. No. 112006 Pat. No. 2705907 Pat. No. 142022 Pat. No. 198426 Pat. No. 076498 Pat. No. 5364737	10/27/1994  8/29/1994 11/24/1994 8/29/1994 9/16/1994 5/15/1998 12/16/1994 19/1995 10/7/1994 10/18/1994 8/30/1994 2/18/1994

Assignee	Docket No.	Title/Description	Filings	Status	Filing Date
M	2522-35-00 (51438)	Waterborne photoresists having non-ionic fluorocarbon surfactants: has claims to a dry film.	EPC: Austria, Belgium, France, Germany, Italy, Liechtenstein, Spain, Switzerland, U.K. Brazil Canada China Hong Kong Israel Japan Korea Mexico Singapore Taiwan U.S.A.	Pat. No. 0664486  Pat. No. 95002561 Pat. No. 2133147 Pat. No. 1071910 Pat. No. 1005151 Pat. No. 112005 Pat. No. 2703732 Pat. No. 149902 Pat. No. 196838 Pat. No. 50509 Pat. No. 085842 Pat. No. 5389495	10/27/1994  1/19/1995 9/28/1994 11/21/1994 5/19/1998 12/16/1994 1/24/1995 11/2/1994 10/18/1994 2/22/1996 9/24/1994 4/6/1994
M	2551-35-00 (51440)	Waterborne photoresists having polysiloxanes: has claims to a dry film.	EPC: Austria, Belgium, France, Germany, Italy, Liechtenstein, Netherlands, Spain, Switzerland, U.K. Australia Canada China Hong Kong Israel Japan Korea Mexico Singapore Taiwan U.S.A.	Pat. No. 0664491  Pat. No. 661438 Pat. No. 21331499 Pat. No. 1072812 Pat. No. 1002939 App No. 112009 Pat. No. 2703731 Pat. No. 149903 Pat. No. 198975 Pat. No. 43816 Pat. No. 085153 Pat. No. 5387494	10/27/1994  9/27/1994 9/28/1994 11/21/1994 3/11/1998 12/16/1994 1/23/1995 11/21/1994 10/18/1994 10/27/1994 9/24/1994 3/30/1994
M	2921-35-00 (51444)	Method of producing a resist pattern by contact imaging a photoimageable composition providing a tack-free surface.	U.S.A.	Pat. No. 5576145	2/10/1995
M	2921-35-01 (51444)	Esterified Styrene/Maleic anhydride polymer and polymer-containing photoimageable compositions having improved alkaline process resistance	U.S.A.	Pat. No. 5698370	9/6/1996

## Schedule 1.1(p)(ii)

The following trademarks are to be transferred to Buyer, subject to an exclusive license to Nichigo-Morton in the Territory as defined in the Joint Venture Agreement between Morton International, Inc. and Nippon-Gohsei. Assignee M refers to Morton International, Inc.

Assignee	Trademark	Country	Status	Next Renewal
M	CONFORMASK	European Community	Registered	01-Apr-2006
M	CONFORMASK	Japan	Registered	30-Aug-2003
M	CONFORMASK	United Kingdom	Registered	09-Apr-2008
M	CONFORMASK	United Kingdom	Registered	09-Apr-2008
M	CONFORMASK	United States	Registered	05-Feb-2011
M	CONFORMASK	Viet Nam	Registered	20-Mar-2003
M	DYNAMASK	Australia	Registered	12-Jul-2007
M	DYNAMASK	Benelux	Registered	13-Jul-2000
M	DYNAMASK	Denmark	Registered	05-Jun-2012
M	DYNAMASK	Finland	Registered	05-Aug-2012
M	DYNAMASK	France	Registered	27-Jul-2000
M	DYNAMASK	Germany	Registered	16-Jul-2010
M	DYNAMASK	Hong Kong	Registered	04-Aug-2011
M	DYNAMASK	India	Registered	13-Jul-2004
M	DYNAMASK	Italy	Registered	31-Jul-2000
M	DYNAMASK	Japan	Registered	31-Oct-2004
M	DYNAMASK	Korea, Republic of	Registered	26-Feb-2003
M	DYNAMASK	Malaysia	Registered	25-Jul-2007
M	DYNAMASK	Norway	Registered	29-Jul-2003
M	DYNAMASK	Singapore	Registered	18-Jul-2007
M	DYNAMASK	South Africa	Registered	16-Jul-2000
M	DYNAMASK	Spain	Registered	19-Jul-2000
M	DYNAMASK	Sweden	Registered	19-Mar-2003
M	DYNAMASK	Switzerland	Registered	10-Jul-2010
M	DYNAMASK	Taiwan	Registered	15-Apr-2001
M	DYNAMASK	United Kingdom	Registered	19-Jul-2007
M	DYNAMASK	United States	Registered	27-Nov-2010
M	DYNAMASK	Viet Nam	Registered	20-Mar-2003
M	DYNAMASK IN CHINESE	Hong Kong	Registered	22-Oct-2011
M	DYNAMASK IN CHINESE	Singapore	Registered	07-Sep-2007
M	LAMINAR	Australia	Registered	08-Oct-2009
M	LAMINAR	Australia	Registered	08-Oct-2009
M	LAMINAR	Benelux	Registered	01-Oct-2004
M	LAMINAR	European Community	Registered	01-Apr-2006
M	LAMINAR	France	Registered	13-Mar-2004
M	LAMINAR	Hong Kong	Registered	30-Mar-2008
M	LAMINAR	India	Registered	03-Oct-2009
M	LAMINAR	Italy	Registered	07-Oct-2004
M	LAMINAR	Japan	Registered	30-Apr-2012
M	LAMINAR	Korea, Republic of	Registered	2005
M	LAMINAR	Malaysia	Registered	2011



M	LAMINAR	Mexico	Registered	08-Apr-2011
M	LAMINAR	Norway	Registered	14-Jun-2009
M	LAMINAR	Singapore	Registered	21-Nov-2011
M	LAMINAR	South Africa	Registered	18-Sep-2004
M	LAMINAR	Sweden	Registered	08-Aug-2005
M	LAMINAR	Taiwan	Registered	01-Apr-2005
M	LAMINAR	United Kingdom	Registered	25-Apr-2008
M	LAMINAR	United States	Registered	22-Aug-2012
M	LAMINAR	Viet Nam	Registered	20-Mar-2003

**Schedule 1.1(p)(iii)**

The following trademarks are to be transferred to Buyer. Assignee S refers to Seller.

Assignee	Trademark	Country	Status	Next Renewal
S	ProEtch		Not Registered	
S	ProTent		Not Registered	
S	ProPlate		Not Registered	

### Schedule 1.1(p)(iii)

Seller or its Selling Affiliate has granted an exclusive license to Nichigo-Morton in the Territory, as defined in the Joint Development Agreement between Morton International, Inc. and Nippon-Gohsei, to certain know-how relating to products listed below sold by Morton International, Inc. in Japan as of the date of the license to Nichigo-Morton and any enhanced or refined versions thereof.

#### Dryfilm Products

AX1.0	AX1.5	AX2.0	UF0.5	UF1.5	LC300
HG1.0	HG1.5(TK1.5)		GH2.0	GA1.0	GA1.3
GA2.0	GA3.0	GA4.0	LP2.0	LP3.0	VG0.5
AP2.0	AT1.2	TE1.0	TE1.3	TE1.5	TE2.0
5020	5038	5050			

#### Soldermask Products

Conformask2015	Conformask2023	Conformask2515	Conformask2523
DM3.0	DM4.0	Dynamask 5010	Dynamask 5030
Dynamask 5040	KM3.0	KM4.0	